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Inventor Information for 10/750871

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US 20050286562 A1	20051229	Method and apparatus for transmitting signals, and method and apparatus for receiving the signals	370/477		Nakao, Seigo et al.
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US 20050280907 A1	20051222	Optical pickup lens device and information recording and reproducing device using the same	359/754		Hayashi, Katano et al.
US 20050250796 A1	20051110	Heterocyclic compounds	514/264.1	514/300; 544/279; 546/122	Yamada, Tatsuhiro et al.
US 20050225619	20051013	Ink used in inkjet recording, method for inkjet recording,	347/100		Fukuda, Toshio et al.

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US 20050202958 A1	20050915	Catalysts for polymerization or copolymerization of alphaolefins, catalyst components thereof, and processes for polymerization of alpha-olefins with the catalysts	502/118	502/103; 502/124; 502/167; 526/125.3; 526/128; 526/905	Yoshikiyo, Motozo et al.
US 20050164655 A1	20050728	Method and apparatus for transmitting signals, method and apparatus for receiving the signals, and communication system utilizing the same	455/101		Nakao, Seigo et al.
US 20050163264 A1	20050728	Correlator and receiving apparatus utilizing the same	375/343		Nakao, Seigo et al.
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		apparatus, computer, video recording/reproducing apparatus, video reproducing apparatus, server and car navigation system			
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US 20040109242 A1	20040610	Optical element, optical lens, optical head apparatus, optical information apparatus, computer, optical information medium player, car navigation system, optical information medium recorder, and optical information medium server	359/738		Komma, Yoshiaki et al.
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US 20040004913 A1	20040108	Optical element, optical head, method for correcting spherical aberration, and optical recording/reproducing apparatus	369/44.32	369/112.23	Wada, Hidenori et al.
US 20030229440 A1	20031211	Control apparatus for vehicle	701/114	477/110; 701/102; 701/110	Tanaka, Yasuhiro et al.
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US 20030001202 A1	20030102	Semiconductor device	257/330	257/E29.009; 257/E29.021; 257/E29.13; 257/E29.133; 257/E29.256; 257/E29.268	Kitamura, Akio
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US 20020196428 A1	20021226	Device for calculating diffraction efficiencies of a diffraction lens, lens with grating element, and optical system for reading	356/124	359/569; 382/286	Yamagata, Michihiro et al.
US 20020190341	20021219	Semiconductor device with a protective diode having a high	257/499	257/E29.064; 257/E29.268	Kitamura, Akio

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US 6025669 A	20000215	Piezoelectric resonator and piezoelectric components using the same	310/364	310/355	Tanaka; Yasuhiro
US 6011709 A	20000104	Semiconductor memory with built-in cache	365/49	365/230.09	Tanaka; Yasuhiro et al.
US 5989617 A	19991123	Method of assessing wheat or wheat flour regarding suitability for producing noodles	426/549	127/29; 127/32; 426/451; 426/661	Akashi; Hajime et al.
US 5986779 A	19991116	Multiple focus lens, an optical head apparatus and an optical information recording-reproducing apparatus	359/19	359/16; 359/566; 359/570; 365/216	Tanaka; Yasuhiro et al.
US 5983008 A	19991109	Method for designing layout of semiconductor integrated circuit, semiconductor integrated circuit obtained by the same method, and method for verifying timing thereof	716/6	703/19	Kumashiro; Shinichi et al.
US 5981997 A	19991109	Horizontal field effect transistor and method of manufacturing the same	257/335	257/336; 257/343; 257/E21.417; 257/E29.054; 257/E29.256	Kitamura; Akio
US 5929677 A	19990727	Phase locked loop having a voltage source responsive to a filtered phase difference output voltage and semiconductor device including the phase locked loop	327/157	327/147; 327/148; 327/156; 331/17	Murata; Toshihiko
US 5923569 A	19990713	Method for designing layout of semiconductor integrated circuit semiconductor integrated circuit obtained by the same method and method for verifying timing thereof	716/7	257/E27.108; 716/14; 716/18; 716/4	Kumashiro; Shinichi et al.
US 5917217 A	19990629	Lateral field effect transistor and method of manufacturing the same	257/343	257/339; 257/492; 257/E27.064; 257/E29.256	Kitamura; Akio et al.
US 5916619 A	19990629	Fried instant noodles and method for manufacturing the same	426/557	426/18; 426/28; 426/451; 426/555; 426/622	Miyazaki; Eiji et al.
US 5909758	19990608	Supporting tool and method of	16/406	248/205.3;	Kitamura;

A		installing same	<u> </u>	248/205.6;	Akio
Α		installing same		248/205.8;	AKIO
				· ·	
				248/206.3;	
110 5005050	10000000	I de la la MODET	420/202	248/544	T2 ** 1 *
US 5885878	19990323	Lateral trench MISFET and	438/302	148/DIG.126;	Fujishima;
A		method of manufacturing the		148/DIG.151;	Naoto et al.
		same		257/E21.418;	
				257/E21.419;	
				257/E29.256;	
				257/E29.258;	
				257/E29.26;	
				438/297;	
		•		438/306;	
				438/307	
US 5875148	19990223	Semiconductor memory	365/230.06	257/E27.097;	Tanaka;
A		ř		365/189.11	Yasuhiro et al.
US 5844275	19981201	High withstand-voltage lateral	257/335	257/336;	Kitamura;
A		MOSFET with a trench and		257/343;	Akio et al.
		method of producing the same		257/E21.417;	
		mound of producing the same		257/E29.021;	
				257/E29.256;	
				257/E29.258;	
				257/E29.268	
US 5830981	19981103	Process for producing	528/283	524/714;	Koreishi;
	19961103		320/203	524/714, 524/765;	Hiroshi et al.
A		polyethylene terephthalate		,	fillosiii et ai.
				524/773;	
				528/274;	
				528/308.2;	
				528/308.4;	
				528/308.5;	
				528/308.6;	
		·		528/499;	
				528/502R;	
	,			528/503	
US 5824951	19981020	Electronic part comprising a	174/564	257/E23.193;	Tanaka;
Α		casing with a narrow groove		310/348;	Yasuhiro
		formed in the casing		361/728	
US 5814806	19980929	Code sheet representing multiple	235/494	235/462.01	Tanaka;
Α		code information and method for			Yasuhiro et al.
	İ	producing the same			
US 5781466	19980714	Semiconductor memory with	365/49	365/149;	Tanaka;
A		built-in cache		365/230.09	Yasuhiro et al.
US 5760440	19980602	Back-source MOSFET	257/328	257/329;	Kitamura;
A				257/330;	Akio et al.
= -				257/334;	
				257/336;	
	1			257/492;	
				257/493;	
				257/E27.064;	
		<u> </u>	<u> </u>	23 11 E 2 1 . 0 0 4 ,	

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				257/E29.021;	
				257/E29.256;	
				257/E29.26;	
				257/E29.262;	
				257/E29.267;	
				257/E29.268	
US 5757216	19980526	Electronic device using phase	327/156	327/147;	Murata;
	19980320		327/130	331/14;	Toshihiko
A		synchronous circuit			TOSIIIIKO
110 5505005	10000107		71.6/0	331/17	m 1
US 5737237	19980407	Method and apparatus for data	716/9	716/8	Tanaka;
A		path circuit layout design and			Yasuhiro et al.
		memory medium for causing			
		computer to execute data path			
		circuit layout design			
US 5705842	19980106	Horizontal MOSFET	257/362	257/281;	Kitamura;
A				257/335;	Akio et al.
				257/343;	
				257/358;	
				257/360;	
				257/361;	
				1	
				257/363;	
				257/373;	
				257/379;	
				257/449;	
			1	257/473;	
				257/E29.258	
US 5701026	19971223	Lateral trench MISFET	257/510	257/335;	Fujishima;
A				257/374;	Naoto et al.
				257/E21.418;	
				257/E21.419;	
				257/E29.256;	
				257/E29.258;	
				257/E29.26	
US 5684641	19971104	Objective lens and optical head	359/719	359/710;	Tanaka;
	199/1104	1 2	333//19		Yasuhiro et al.
Α		apparatus using the objective		359/711;	r asumro et al.
VIG #650050	10070010	lens	226/69	369/112.23	T. 1
US 5659258	19970819	Level shifter circuit	326/68	326/81;	Tanabe;
<u>A</u>				326/83	Tetsuya et al.
US 5652727	19970729	Semiconductor memory device	365/203	365/202	Tanaka;
A					Yasuhiro et al.
US 5651006	19970722	Hierarchical network	370/408	370/902;	Fujino; Shuji
Α		management system		709/223;	et al.
				710/120	
US 5636048	19970603	Equalizing amplifier, receiver	398/202	330/278;	Kogure;
Α		using the same and preamplifier		330/291;	Kazuhisa et al.
- -		Programme Prog		330/304;	
				398/208	
US 5633525	19970527	Lateral field effect transistor	257/381	257/141;	Kitamura;
	199/032/	Lateral Held effect transistor	25//501	1	Akio et al.
<u>A</u>	<u> </u>			257/343;	AKIO EL al.

257/401;	
257/E23.015;	
257/E29.12;	
257/E29.268	
US 5631307 19970520 Photopolymerization initiator 522/25 522/31 Tanaka;	
A composition and Yasuhiro	et al.
photopolymerizable composition	
US 5596521 19970121 Semiconductor memory with 365/49 365/149 Tanaka;	
A built-in cache Yasuhiro	et al
US 5591657 19970107 Semiconductor apparatus 438/202 257/E21.417; Fujishim	
	ai.
employing gate side wall self-	
aligning for masking 257/E29.268;	
438/208;	
438/286;	
438/305	
US 5586255 19961217 Network management operation 709/223 715/700 Tanaka;	
A system and network Yasuhiro	et al.
management operation method	
US 5577223 19961119 Dynamic random access 711/118 365/230.03; Tanoi; Sa	toru
A memory (DRAM) with cache 365/49; et al.	
and tag 711/105	
US 5573888 19961112 Image transfer method 430/256 430/257; Imabayas	hi:
A 430/273.1 Arata et a	-
US 5566115 19961015 Semiconductor memory device 365/203 369/180; Tanaka;	<u></u>
A 369/202; Yasuhiro	et al
369/226 Tasumo	Ct al.
US 5535058 19960709 Focus error detecting element 359/711 359/719 Tanaka;	
	ot al
US 5523599 19960604 High voltage MIS field effect 257/327 257/335; Fujishim	-
A transistor 257/343; Naoto et	aı.
257/401;	
257/653;	
257/E29.012;	
257/E29.027;	
257/E29.12;	
257/E29.256;	
257/E29.258	
US 5511030 19960423 Semiconductor memory device 365/203 365/190 Tanaka;	
A and method of driving same Yasuhiro	et al.
US 5502323 19960326 Lateral type field effect 257/335 257/341; Kitamura	
A transistor 257/401; Akio et a	
257/E23.145; Takko et a	-•
257/E23.152;	
257/E23.132, 257/E29.027;	
257/E29.12;	
257/E29.256;	
257/E29.268	
US 5477496 19951219 Semiconductor memory device 365/203 365/202 Tanaka;	

A		having circuits for precharging and equalizing			Yasuhiro et al.
US 5473471 A	19951205	Complex lens with diffraction grating	359/569	359/566; 359/571; 359/574; 359/741; 359/742; 369/112.08	Yamagata; Michihiro et al.
US 5471399 A	19951128	Network management system and network status display method	716/11	370/241; 714/47; 714/57; 715/733; 715/839; 715/969; 716/8	Tanaka; Yasuhiro et al.
US 5461259 A	19951024	High-current integrated circuit	257/758	257/401; 257/776; 257/E27.06	Kitamura; Akio et al.
US 5451671 A	19950919	Method of purifying 2',3'-dideoxynucleosides	536/27.12	536/27.14; 536/28.2	Shiragami; Hiroshi et al.
US 5438665 A	19950801	Direct memory access controller for handling cyclic execution of data transfer in accordance with stored transfer control information	710/25	710/28	Taniai; Takayoshi et al.
US 5436486 A	19950725	High voltage MIS transistor and semiconductor device	257/378	257/140; 257/146; 257/577; 257/E29.064; 257/E29.197	Fujishima; Naoto et al.
US 5432370 A	19950711	High withstand voltage M I S field effect transistor and semiconductor integrated circuit	257/339	257/336; 257/337; 257/343; 257/401; 257/E27.06; 257/E29.015; 257/E29.017; 257/E29.027; 257/E29.066; 257/E29.256; 257/E29.258	Kitamura; Akio et al.
US 5414917 A	19950516	Method of manufacturing piezoelectric resonator chips	29/25.35	310/340	Tanaka; Yasuhiro
US 5317792 A	19940607	Method of manufacturing piezoelectric resonator	29/25.35	29/411	Tanaka; Yasuhiro
US 5310895 A	19940510	Method for production of nucleoside derivatives by selective hydrolysis	536/27.14	536/103; 536/27.6; 536/27.62;	Shiragami; Hiroshi et al.

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				536/27.63;	
				536/27.81;	
				536/28.2;	
				536/28.5;	
				536/28.53;	
				1	
				536/28.54	
US 5270444	19931214	Process for treatment of	528/499	528/308.2;	Shiraki;
Α		polyethylene terephthalate,		528/308.4;	Shigemi et al.
		polyethylene terephthalate for		528/308.5;	
		molding purposes and process		528/503	
		for preparation thereof			
US 5241046	19930831	Process for treatment of	528/499	528/308.2;	Shiraki;
	19930631		320/433	1	1
Α		polyethylene terephthalate,		528/308.4;	Shigemi et al.
		polyethylene terephthalate for		528/308.5;	
		molding purposes and process		528/503	
		for preparation thereof			
US 5213166	19930525	Pile driving and pile removing	173/1	175/65	Watanabe;
A		method			Naotaka et al.
US 5159302	19921027	Ladder type band-pass filter	333/189	310/348;	Tanaka;
A	13321027	comprising of assembled plural	355/105	310/355	Yasuhiro
A				310/333	1 asullio
TTG 5110105	10000000	vibrator blocks	-10/00		
US 5119487	19920602	DMA controller having	710/22		Taniai;
Α		programmable logic array for			Takayoshi et
		outputting control information			al.
		required during a next transfer			
		cycle during one transfer cycle			
US 5068849	19911126	Cyclic data transmission method	370/509	370/452	Tanaka;
A	13311120	Syone data transmission medica	370/303	3707132	Yasuhiro
US 5043935	19910827	Data transfer system for	710/66		Taniai;
	19910827	Data transfer system for	/10/00		1
A		rearranging data units using			Takayoshi et
<u> </u>		intermediate temporary registers			al.
US 5033017	19910716	Programmable logic array with	708/232	326/105;	Taniai;
Α		reduced power consumption		326/38;	Takayoshi et
		•		326/44	al.
US 4998246	19910305	Method for transmission of	370/452		Tanaka;
A	13310303	cyclic data	3707132		Yasuhiro
US 4980890	10001225		714/735		
	19901225	Semiconductor integrated circuit	/14//33		Taniai;
A		-			Takayoshi et
					al.
US 4927247	19900522	Objective lens for optical disk	359/708		Tanaka;
Α		system and optical head using			Yasuhiro et al.
		the same			
US 4842388	19890627	Single optical lense with	359/718		Tanaka;
	17070027	diffraction limit converging	337//18		Yasuhiro et al.
A					i asumito et al.
		capability and wide field angle	0101515	10101555	
		I Industion booting sail for boot	1 210/6/12	219/632;	Umemoto;
US 4786772	19881122	Induction heating coil for heat-	219/643	1	•
US 4786772 A	19881122	treating metallic tubes	219/043	219/674; 266/129	Tadahiro et al.

US 4695756	19870922	Laminated terminal layer for	310/355	310/326;	Tanaka;
A		electronic component		310/354; 310/364	Yasuhiro
US 4693571 A	19870915	Support and drive unit for mirror devices	359/874	359/877	Kimura; Sakae et al.
US D291461 S	19870818	Reconfigurable toy vehicle	D21/582		Kitamura; Akio
US D290723 S	19870707	Reconfigurable toy vehicle	D21/581		Kitamura; Akio
US D290630 S	19870630	Reconfigurable toy tank	D21/580		Kitamura; Akio
US D290481 S	19870623	Reconfigurable toy boat	D21/580		Kitamura; Akio
US 4656385 A	19870407	Housing having grooves therein for mounting a piezoelectric ladder filter	310/348	174/549; 174/560; 333/189	Tanaka; Yasuhiro
US 4641055 A	19870203	Piezoelectric resonator with notched sides	310/368	310/312	Tanaka; - Yasuhiro
US 4582469 A	19860415	Intake valve apparatus in air pump	417/571	137/855	Asaka; Urataro et al.
US 4551074 A	19851105	Air pump apparatus	417/366	417/415; 417/440; 92/158	Asaka; Urataro et al.
US 4323865 A	19820406	Ladder-type piezoelectric filter	333/187	310/348; 333/189; 333/190	Tanaka; Yasuhiro et al.

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